

## Supporting Information

# A Novel porous Ti/TiN/Ti thin film as working electrode for back-contact, monolithic and non-TCO dye-sensitized solar cells

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Table S1. Summary of sheet resistivity and film thickness for sputtered TiN thin film under various nitrogen flows and Ti-TiN-Ti thin film.




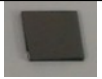
					Ti-TiN-Ti thin film
N <sub>2</sub> / (Ar + N <sub>2</sub> ) flow ratio	0.6/(0.6+30)	1.0/(1.0+30)	1.5/(1.5+30)	2.5/(2.5+30)	
Sheet resistivity (Ω/□)	2.38	4.10	5.27	13.30	7.74
Film thickness (nm)	560	500	450	330	450

Table S2. Complete photovoltaic performances of BC-DSCs and Ref-DSCs using photoanodes with various thickness of TiO<sub>2</sub> layer sensitized with Z-907 dye and MK-2 dye, respectively.

	TiO <sub>2</sub> Thickness (μm)	V <sub>OC</sub> (mV)	J <sub>SC</sub> (mA/cm <sup>2</sup> )	FF	PCE (%)
BC-DSCs Z-907	2.3	780	3.13	0.71	1.73
	4.0	740	6.88	0.71	3.69
	8.8	720	8.25	0.70	4.17
	10.6	720	9.06	0.69	4.53
	14.8	700	8.07	0.68	3.90
BC-DSCs MK-2	2.3	760	6.50	0.72	3.55
	4.0	740	7.53	0.71	3.95
	8.8	740	7.88	0.71	4.16
	10.6	720	7.38	0.69	3.68
	14.8	720	6.74	0.68	3.29
	TiO <sub>2</sub> Thickness (μm)	V <sub>OC</sub> (mV)	J <sub>SC</sub> (mA/cm <sup>2</sup> )	FF	PCE (%)
Ref-DSCs Z-907	2.3	780	6.53	0.77	3.94
	4.0	760	8.58	0.74	4.8
	8.8	760	10.63	0.72	5.80
	10.6	740	11.25	0.72	6.0
	14.8	740	9.75	0.71	5.17
Ref-DSCs MK-2	2.3	780	7.44	0.71	4.11
	4.0	760	8.31	0.71	4.51
	8.8	760	10	0.70	5.36
	10.6	740	9.75	0.68	4.87
	14.8	720	8.81	0.66	4.17

Table S3. Photovoltaic parameters of BC-DSCs using 350 nm Ti-TiN-Ti electrode with Z-907 dye and MK-2 dye.

	TiO <sub>2</sub> Thickness (μm)	V <sub>OC</sub> (mV)	J <sub>SC</sub> (mA/cm <sup>2</sup> )	FF	PCE (%)
BC-DSCs Z-907	11.3	740	5.39	0.64	2.58
BC-DSCs MK-2	9.0	783	5.71	0.68	3.04

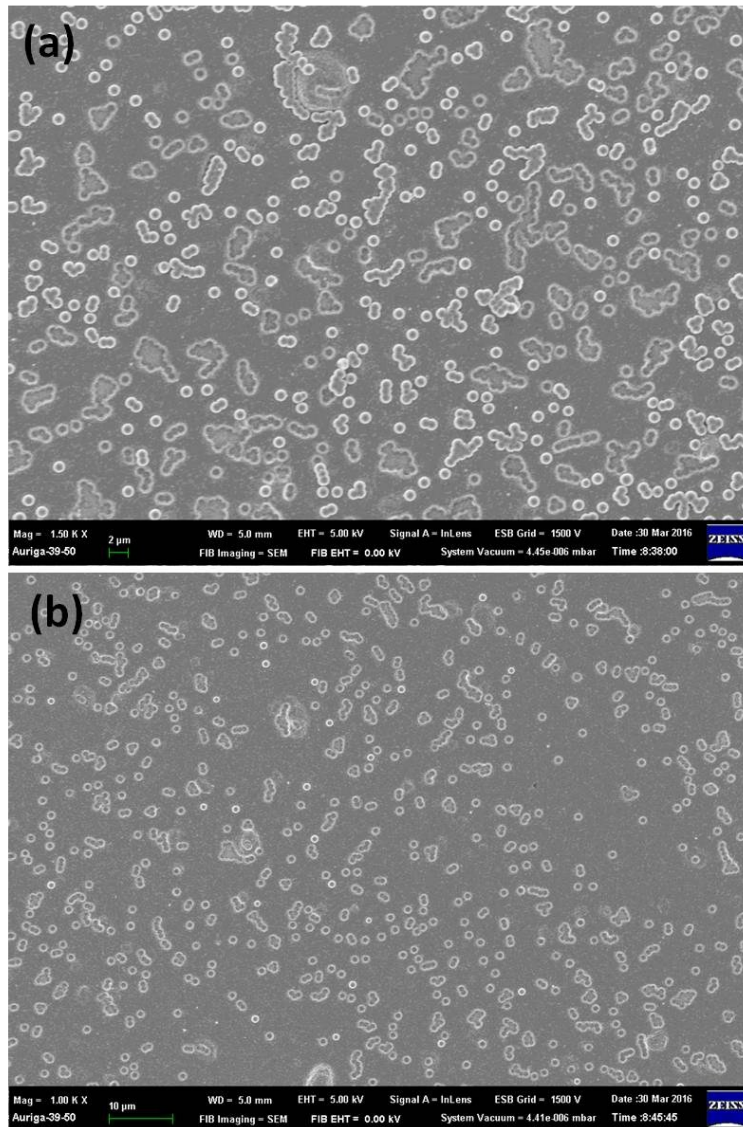


Figure S1. The SEM image for (a) incomplete and (b) complete removal of polystyrene balls

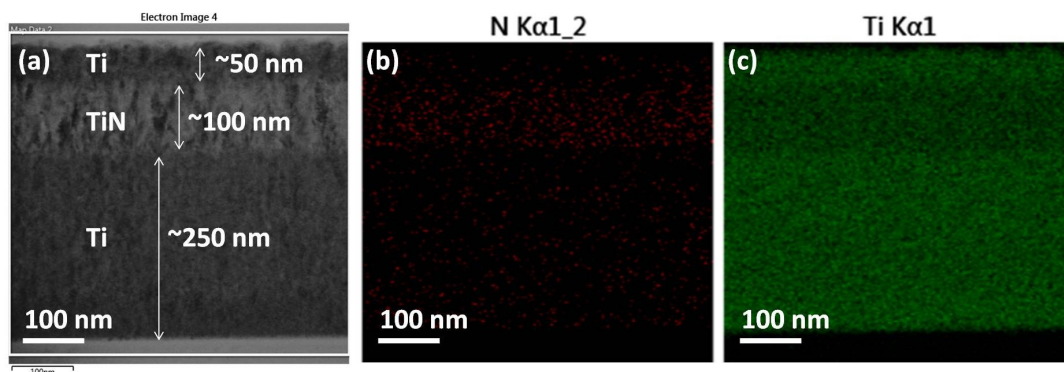


Figure S2. (a) Cross-sectional TEM image of Ti-TiN-Ti tri-layer deposited on glass substrate. Energy dispersive X-ray spectroscopy (EDX) mapping of relevant elements of (b) N, and (c) Ti for Ti-TiN-Ti tri-layer.

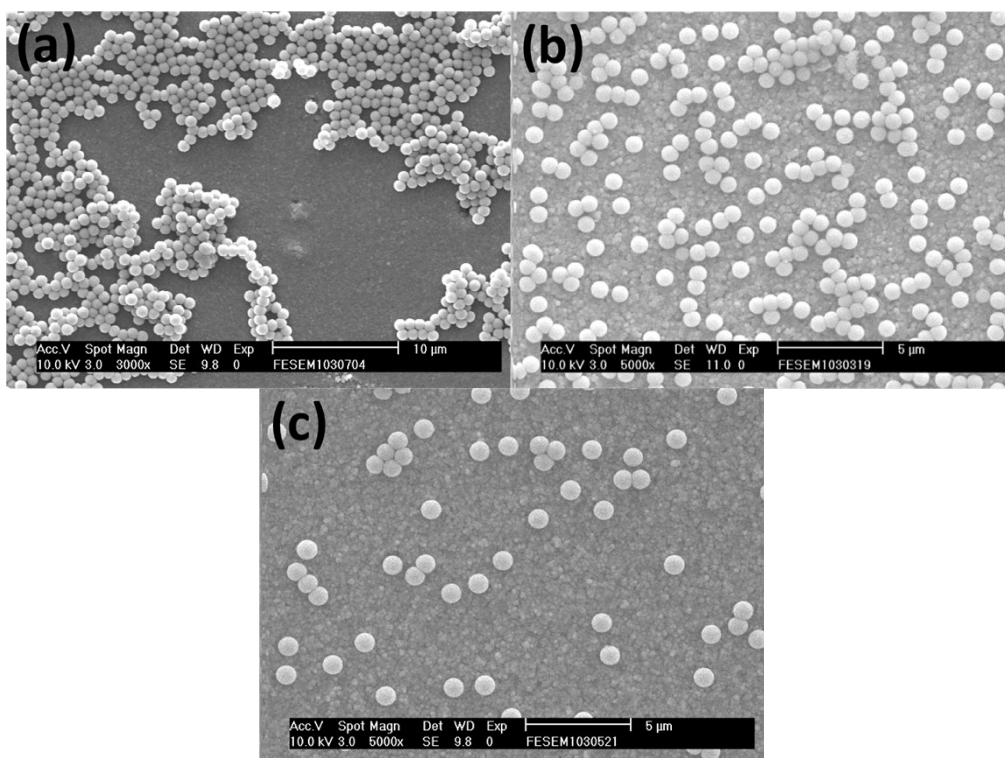


Figure S3. SEM images of polystyrene distributed on meso-TiO<sub>2</sub> layer after deposition of Ti-TiN-Ti thin films resulting from solution of (a) polystyrene:ethanol (1:50), (b) polystyrene:ethanol (1:99), and (c) polystyrene:ethanol (1:199).

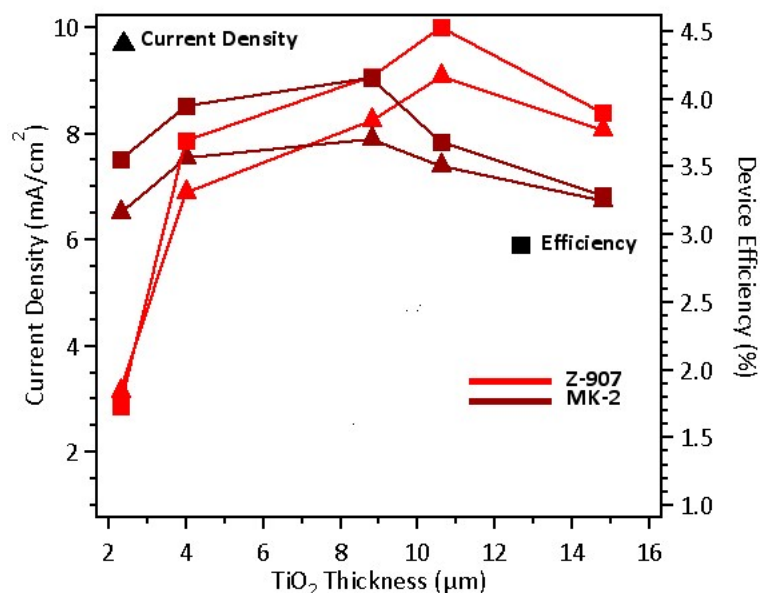


Figure S4. The dependence of TiO<sub>2</sub> layer thickness versus short-circuit current density and device efficiency for BC-DSCs sensitized with Z-907 dye and MK-2 dye.